

Docket No. AMDP440001A

2/12

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re **PATENT** application of:

Applicant: Choo et al.

Filing Date: Herewith

Title: OPTIMIZATION OF OPC DESIGN FACTORS UTILIZING  
AN ADVANCED ALGORITHM ON A LOW VOLTAGE  
CD-SEM SYSTEM

**PRELIMINARY AMENDMENT**

Box Patent Application  
Assistant Commissioner for Patents  
Washington, D.C. 20231

Sir:

Please amend the above-identified application as indicated below.

**In the Specification:**

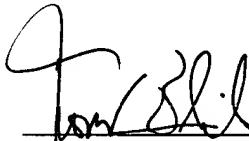
Page 1, after the title, insert the following paragraph:

**--Related Application**

This application claims priority to the provisional application Serial No.  
60/200,322 filed April 28, 2000, which is entitled "Optimization of OPC Design Factors  
Utilizing an Advanced Algorithm on a Low Voltage CD-SEM System".--

Respectfully submitted,

AMIN, ESCHWEILER & TUROCY, LLP



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